

Plasma Etching: Fundamentals And Applications (Semiconductor Science And Technology) By M. Sugawara

By M. Sugawara

AVS - Plasma Etching and RIE: Fundamentals and -
Course Objectives The Fundamentals. Know the basic concepts of plasma etching. Understand the physics of RF glow discharges (both high and low density).

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Handa M L - AbeBooks -

Handa, M. L. Published by Plasma Etching: Fundamentals and Applications (Semiconductor Science and Technology) M. Sugawara, Barry L. Stansfield (Contributor),

<http://www.abebooks.com/book-search/author/handa-m-l/>

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k dielectric layers during etching. SEMICONDUCTOR SCIENCE AND TECHNOLOGY, O2 Plasma Etching on Molecules: Fundamentals and Applications,

<http://dcu.ie/physics/people/greg-hughes.shtml>

Nanotechnology - Wikipedia, the free encyclopedia -

Development of applications incorporating semiconductor nanoparticles to which is then followed by an etching process to Environmental science & technology 42

<https://en.wikipedia.org/wiki/Nanotechnology>

Nonlinear gain dynamics of quantum dot optical -

Semiconductor Science and Technology Volume 26 Number 1 Ebe H and Sugawara M 2003 Phys. Status Solidi (b) applications and possible laws

<http://iopscience.iop.org/0268-1242/26/1/014008/refs>

Erosive wear resistance of NCD coatings produced -

The erosive wear resistance of NCD was evaluated by M. Sugawara; Plasma Etching: Fundamentals and Applications, in: Series on Semiconductor Science and Technology, 7.

<http://www.sciencedirect.com/science/article/pii/S0925963509003100>

Books: Plasma Etching: Fundamentals and -

Author: M. Sugawara, Title: Plasma Etching: Fundamentals and Applications (Semiconductor Science and Technology) (Hardcover), Publisher: Oxford University Press

<http://www.tower.com/plasma-etching-fundamentals-applications-barry-l-stansfield-hardcover/wapi/100830285>

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Plasma Etching: Fundamentals and Applications (Series on Semiconductor Science and Technology) [M. Sugawara, Barry L. Stansfield, S. Handa, K. Fujita, S. Watanabe, T

<http://www.amazon.com/Plasma-Etching-Fundamentals-Applications-Semiconductor/dp/019856287X>

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<http://www.kocebu.com/v4/263.pdf>

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<http://www.openisbn.com/isbn/9780124693708/>

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telecommunications will be driven by future developments in
semiconductor science and technology. .

<http://link.springer.com/content/pdf/bfm%3A978-94-011-2714-1%2F1.pdf>

Patent US20140187666 - Slippery liquid-infused -

A. et al., Science 318 using the Bosch reactive ion etching
method (as described in Plasma Etching: Fundamentals and
Applications, M. Sugawara,

<http://www.google.com/patents/US20140187666>

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<https://global.oup.com/academic/product/plasma-etching-9780198562870>

Magnetically confined plasma reactive ion etching -

References from the article Magnetically confined plasma
reactive ion etching and Semiconductor Science and Technology
Fundamentals of Plasma

<http://iopscience.iop.org/0268-1242/10/10/015/refs>

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